

Recent 1.3 GHz 9-cell Cavity Results

J. Kerby, C. M. Ginsburg (Fermilab) AES Site Visit 24 February 2010

Contents



- Current Summary of ILC 9 cell 1.3GHz Cavity Performance
 - Worldwide summary
 - Company Progress
- AES001-010 History
 - Processing Cycles and Results
 - Selected Inspection Comments
- Summary

1.3 GHz 9-cell Cavity Production

- XFEL, and now ILC (including ARRA funds), are the major drivers for 9 cell development worldwide
- Results from past 3 years have been collected in worldwide database, as a means to further track progress and provide input to ILC machine design
 - Focuses on first 2 test cycles, 'production yield'
 - Data from all three regions, from the last few years
 KEK [5 cavities]: (MHI)
 JLab, Cornell, Fermilab [22 cavities]: (Accel/RI, AES, JLab)
 DESY [53 cavities]: (Accel, Zanon)
- Majority of tests in near term in Americas Region
 - ARRA cavities will add important statistics

"Up-to-second-pass" ILC Production

- Cavity from vendors who have manufactured a cavity that has surpassed 35MV/m in vertical test:
 - ACCEL or ZANON or (AES SN>=5)
- Fine-grain cavity
- Use the first successful (= no system problem) test
- Standard EP processing: no BCP, no experimental processes
- (Ignore test limitation)
- Second pass
 - if (Eacc(1st successful test)<35 MV/m) then
 - ➢ if (2nd successful test exists) then
 - o plot 2nd test gradient
 - ≻ else
 - o plot nothing [assume 2nd test didn't happen yet]
 - ➤ endif
 - else
 - > plot 1st successful test gradient
 - endif



Performance typically improves after 2nd pass

>20

>25

max gradient [MV/m]

>30

>35

>40

Summary of ILC Cavity Gradient Status

- Global Database has been created
 - Consistent, reproducible plots incorporating worldwide data
- <u>Production</u>, 2nd pass yield of 44% for vendors with a cavity >35MV/m in vertical test
 - Q0 goals met by all cavities >35MV/m--efforts will continue on this aspect as well
- Considerable number of cavity tests coming in 2010
 - Cavity deliveries and orders keep the system loaded
 - Processing and Test Infrastructure up to speed
 Fermilab completed 6 VTS test cycles in December
 - Better diagnostic equipment in place

Worldwide Vendor Gradient Summary



Zanon (XFEL)





Accel (XFEL)





Accel (Americas)





MHI











Gradient Summary



- Good Progress Worldwide in Cavity Production, Processing, and Test
- Progress is a partnership between industry and laboratories, results are dependent on <u>both</u> performing well
 - Scars, pits, stains, dirt and residue introduced at different steps
 - Early defects are not typically overcome by the standard processing steps
- The typical learning curve at each company requires a 'few' cavities
 - constant vigilance required afterwards to stay there
- Yield statistics to the ILC specification show improvement in the past year
 - Utility of XFEL test data for ILC will be limited by XFEL requirements
- Efforts to exceed ILC gradient spec will continue
 - Field emission prevention at all gradients remains important
- Laboratory Processing and Test facilities are coming up to speed, recent throughput at Fermilab for instance is very good





Status of the AES 9-cell Cavities

Data from JLab, KEK, LANL, FNAL

AES cavity processing @JLab

Processing Recipe J. Mammosser (JLab), TTC Mtg@Fermilab, April 2007 Cumulative Material Removal (microns) R. Geng (JLab), AES Mtg @JLab, Aug 2007

Processing recipe

- Degrease
- Electropolishing (20 µm)
- Degrease
- First HPR+dry
- First cleanroom assembly
- Second HPR+dry
- Final cleanroom assembly
- Evacuation and leak check
- Low temperature (110 C) bake

Note: all cavities get 150 um bulk EP

	1 st test	2 nd test	3 rd test	4 th test
AES001	213	236	252	269
AES002	164	190		
AES003	177	200		
AES004	221	257	277	

Note: updates since August 2007 are not shown

Most of the AES001-4 cavity processing work was done 2006-2007

AES001 Summary



- JLab: 4 process/tests Mar.-May 2007
 - Quench field repeatedly ~17 MV/m; no x-rays measured
 - Pass-band mode measurements implicate cell #3 and #7; confirmed with FNAL fast thermometry to be cell 3 (counting from input coupler)
- Visited PAC07 for LANL show-and-tell
- FNAL: 3 tests Sep.-Dec.2007
 - Only HPR (at JLab) before first test
 - Quench field repeatedly ~16 MV/m; no x-rays measured
 - passband mode measurements and FNAL fast thermometry found hot spot(s) in heat-affected zone
- KEK/Kyoto: Assorted development/commissioning Dec.2007-Dec.2008
 - First demonstration of Kyoto/KEK camera system: double-spot found corresponding to quench location; additional spot found
 - mode measurements imply max gradient anywhere ~lower 20's MV/m; some field emission seen at higher gradients
 - used for STF commissioning, including light EP
 - gradient improved to 22 MV/m; mode measurements imply 6 cells limited to ~lower 20's MV/m, 3 cells could get up to 40 MV/m
- First cavity welded at FNAL into He vessel; some welds not full penetration; used for warm HTS commissioning; do not expect HTS cryogenic test; currently in storage

AES002 Summary



- All surface processing work was done at JLab
- Always quench limited at JLab
 - 19.6,18.0, 26.0, 32.8 MV/m
- Was until recently the best performer of the first AES production batch; had been stored at JLab un-sealed when tapped for dressing
- Fifth Fermilab-dressed cavity initially intended for S1-Global cryomodule
- Vertically tested (dressed) twice at Fermilab with HPR in between; performance degradation to 19 MV/m with FE onset 12 MV/m
 - decision to replace with AES004 in S1-Global
- Currently in storage at Fermilab; good candidate for dressed cavity R&D, e.g., dressed BCP or dressed EP

AES003 Summary



- JLab: 4 process/tests Jun.-Aug. 2007
 - Quench field repeatedly ~18 MV/m; no x-rays measured
 - Pass-band mode measurements implicate cell #4 and #6; confirmed with FNAL fast thermometry to be cell 4 (counting from input coupler)
 - mode measurements imply max gradient anywhere ~lower 20's MV/m; some field emission seen at higher gradients
- FNAL: 2 tests Jan.-Apr. 2008
 - hot(-test) spot found more precisely, mode measurements, first test of variable coupler
- LANL:
 - test stand commissioning and instrumentation development
 - bunch of spots found correlated with thermometry
 - Has been scratched on the iris (see picture next slide)

AES003 scratch

T. Tajima (LANL), TTC 2008, Oct 2008



AES003 Repair



• Sent to KEK for optical inspection (Kyoto/KEK system), local grinding of equator and iris defects, and EP







- FNAL/ANL first test after partial HPR 30 MV/m; field-emission limited; no heating at previous quench site
- FNAL/ANL full HPR cycle, cavity performance improved to 34 MV/m; currently fieldemission limited; additional improvement anticipated

AES004 Summary



- All surface processing work was done at JLab
- Always field-emission limited
 - 28.0, 25.5, 19.5, 21.5, 27.0 MV/m
 - Iris defect found with optical inspection (see next slide)
- Used for HPR commissioning at FNAL/ANL facility
- 2nd dressed cavity at FNAL
- Horizontally tested (first cold RF test at HTS) at FNAL
 - Maximum gradient 25-31 MV/m (calibration needed work), quench limitation, field emission observed
- Currently at KEK for S1-Global cryomodule

S1-Global Cryomodule 4-cavity string completed at KEK



AES004

TB9ACC011

AES004 defect

R. Rimmer (JLab), LCWS 2008, Nov 2008

AES4 High E Field Region

Cavity FE limited even after repeated EP pass-band measurements suggest field emitters in end cells



ferson Lab

Thomas Jefferson National Accelerator Facility



TB9AES005, 6



- FNAL incoming inspection waived for expedience
- TB9AES005
 - Two RF tests with light EP in between
 - ➤ 20.5 MV/m both times
 - defects observed in optical inspection
 - At Cornell for tumbling and VEP
- TB9AES006
 - Two RF tests at JLab with light EP in between
 ➤ 14.1 MV/m, 22.2 MV/m
 - ➤ defects observed in optical inspection
 - Currently in storage at JLab; candidate for tumbling or other remediation

TB9AES007



- FNAL incoming inspection showed void in HOM weld (see photo)
 - No remediation wait and see
- To get final surface process this week at JLab and cold vertical test soon thereafter



TB9AES008,9,10



- All surface processing done at JLab
- TB9AES008
 - Had end group replaced because of assembly error in which end groups were 180 degrees out of alignment; field probe end group was cut off and replaced with spare unit
 - One cold vertical test at JLab
 - 41 MV/m (best ever, and might have gone higher administrative limit)
 - is welded with Ti trans rings and at MP9 now for welding into its helium vessel
- TB9AES009
 - Two vertical tests at JLab: 30.0 MV/m (FE), 36.0 MV/m (quench)
 - Dressed at FNAL
 - Ready for horizontal test; next test cycle in early March
- TB9AES010
 - One cold vertical test at JLab
 - 38.0 MV/m (quench)
 - is welded with Ti rings and at MP9 now (in queue for welding into its helium vessel after TB9AES008)

Performance Summary of AES 2nd



Incoming Inspection



inspection performed by QA specialist; signed off by engineer/physicist

Visual inspection

 adequate packaging, flange sealing surface quality, overall external integrity (no dents or scratches), Nb sheet serial #'s, cavity serial #'s

Leak check

- oil-free leak detection system with sensitivity 2 E-10 atm-cc/sec or better.
- No grease or o-rings on the cavity sealing surface; AI hex seals only
- sealing surfaces may be cleaned with lint-free wipes and alcohol (IPA)
- no detectable helium leak at room temperature
- CMM

•

•

- cavity: straightness, length, bolt clocking, etc.
- transition rings: parallelism, ring diameter, etc.
- Incoming room-temperature field flatness
- cavity is cut out of bag at start and left out of bag at end to reduce handling
- cavity is only touched with nitrile (or equivalent) gloves
- whole process takes about 5 days

Inspection Data Examples







example of noted defect found on HOM flange



example of noted defect found on end flange





- Progress is a partnership between industry and laboratories, results are dependent on <u>both</u> performing well
- The number of vendors making quality cavities has increased in the past couple of years
- Diagnostic and remediation tools have improved dramatically in the past couple of years
- Americas Region will process and test the majority of 9-cell 1.3 GHz cavities in the next year

Backup Slides



Cavity Processing Steps-Details



Cavity Inspection ٠ Allan Rowe Visual Inspection presentation 12 Feb 2010 Sealing surface integrity Free of radial scratches Machining/finishing marks all circumferential Cavity cleanliness Free of oils, finger prints, dirt, and grime No undue discoloration Vapor film from Ebeam welding deposited on exterior of cavity should be removed where possible HOM cans intact No denting, scratches, scrapes, or other marks Cavity labeled clearly and correctly Mechanical Inspection CMM measurements to verify fabrication tolerances Vacuum leak check

Cavity Processing Steps-Details

Fermilab

- Cavity Inspection cont...
 - Optical Inspection (Kyoto camera system)*
 Allan Rowe
 presentation
 - Inner surface scanned for abnormalities
 - RF Inspection
 - Field-flatness measurements (Bead-pull)
 - Frequency measurements
 - Preliminary RF tuning

*AES internal optical inspection technique TBD

12 Feb 2010



Kyoto optical inspection system



RF tuning machine

February 12, 2010

Cavity Processing –Vert. Test



. .

Allan Rowe	Process Step	Required Tool	
presentation 12 Feb 2010	Clean & Degrease	Ultrasonic Tank + UPW	
	Outside BCP (20um)	BCP Tool	
	Bulk Electropolish (120 um)	EP Tool	
FAILURE	Ultrasonically Clean	Ultrasonic Tank + UPW	
	Hydrogen Degasification	Vacuum Oven (800C)	
MODES	RF Tuning	Tuning Machine	
Low field quench!	US Clean + Light EP (20 um)	EP Tool + US Tank + UPW	
	Alcohol Rinse + US Clean	Ultrasonic Tank + UPW	
	High Pressure Rinse	HPR Tool + UPW	
FE!	Clean Assem. & Evacuation	Vacuum Skid + Class 10	
	Low Temperature Bake	Vacuum Oven (120C)	
	Vertical Test		

Processing Cycle – Horiz. Test



*Step eliminated with success for S1 Global Program. Capability still desired for reprocessing poor performing cavities.

Backup Slides



- Progress is a partnership between industry and laboratories, results are dependent on <u>both</u> performing well
- Hand off between company and laboratory is dependent on capabilities and expertise developed at company, but quality always has to be verified at the handoff point
- Qualification / Verification of new processes / steps in a process requires careful planning